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SC174 U.S. PRO
09/683088

		Subclass
	Class	ISSUE CLASSIFICATION

PATENT NUMBER

U.S. UTILITY Patent Application

O.I.P.E.	PATENT DATE
 SCANNED <u>TR3</u> O.A. <u>Am</u>	

APPLICATION NO. 09/683088	CONT/PRIOR	CLASS 438 17	SUBCLASS 7	ART UNIT 1765	EXAMINER Song
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Jack Chu
Basant Jagannathan
Ryan Wuthrich

Single reactor, multi-pressure chemical vapor deposition for semiconductor devices

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PTO-2040
12/99

ISSUING CLASSIFICATION

TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	<div style="text-align: center;">(Assistant Examiner) _____ (Date) _____</div>			NOTICE OF ALLOWANCE MAILED	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____				<div style="text-align: center;">(Primary Examiner) _____ (Date) _____</div>	
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	ISSUE FEE				
	Amount Due	Date Paid			
				ISSUE BATCH NUMBER	
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